Dedicated to my parents & my brother

Declaration by the Candidate

I, Dhanjit Talukdar, declare that the thesis entitled "Investigation of electronic,

optical, and surface adsorption properties in engineered black phosphorene and its

isostructural tin sulfide systems" is a record of my own work carried out under the

supervision of Prof. Gazi Ameen Ahmed during the period from October, 2021 to May,

2025. I confirm that:

• This work was done wholly or mainly while in candidature for a research degree in

Doctor of Philosophy at Tezpur University where no part of this thesis has previously

been submitted for a degree or any other qualification at this university or any other

institution.

• Where I have quoted from the work of others, the source is always given. With the

exception of such quotations, this thesis is entirely my own work. I have

acknowledged all main sources of help.

• Where the thesis is based on work done by myself jointly with others, I have made

clear exactly what was done by others and what I have contributed myself.

Date: 8th September, 2025

Place: Tezpur, Assam, India

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Certificate by the Supervisor

This is to certify that the thesis entitled "Investigation of electronic, optical, and surface adsorption properties in engineered black phosphorene and its isostructural tin sulfide systems", submitted to the School of Sciences, Tezpur University in partial fulfilment for the award of the degree of Doctor of Philosophy in Physics is a record of original research work carried out by Mr. Dhanjit Talukdar under my supervision and guidance.

All help received by him from various sources have been duly acknowledged. No part of this thesis has been submitted elsewhere for award of any other degree.

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List of Abbreviations

OD Zero-Dimensional1D One-Dimensional2D Two-Dimensional

ac armchair

AIMD Ab-Initio Molecular Dynamics

BNNT Boron Nitride Nanotube

BP Black Phosphorene

BSE Bethe-Salpeter Equation

BZ Brillouin Zone

CB Conduction Band

CBM Conduction Band Minimum
CDD Charge Density Difference

CNT Carbon Nanotube

DFT Density Functional Theory

EBE Exciton Binding Energy

GGA Generalized-Gradient-Approximation

GW Green's function 'G' with screened Coulomb potential 'W'

h-BN Hexagonal Boron Nitride

HF Hartree-Fock

HVB Highest Valence Band

IDE Interdimensional Exciton

IFE Interfacial Exciton

KS Kohn-Sham

LCB Lowest Conduction Band

LDA Local Density Approximation

MBPT Many-Body Perturbation Theory

ONCPPSP Optimized Norm-Conserving Vanderbilt Pseudopotential

PAW Projector Augmented-Wave

PDOS Projected Density of States

PPA Plasmon-Pole Approximation

PV Photovoltaics
QP Quasiparticle

RPA Random Phase Approximation

SCF Self-Consistent Field

SnS Tin(II) Sulfide

TMDC Transition Metal Dichalcogenide

TMMC Transition Metal Monochalcogenide

VB Valence Band

VBM Valence Band Maximum

vdW Van der Waals

zz zigzag

List of Symbols

h Planck's constant

 U_{ei} electron-ion interaction

 W^H Hartree potential

T kinetic energy operator

H Hamiltonian

e electron

N number of electrons

 U_{ee} electron-electron interaction

 $T_{\text{TF}}[n]$. Thomas-Fermi kinetic energy functional

n(r) electron density

 Ψ wavefunction

 E_{el} electronic energy

F[n] universal functional

 V_{ext} external potential

 $E_{xc}[n]$ exchange-correlation energy

 $v_{KS}(r)$ Kohn-Sham potential

 $V_{xc}(r)$ exchange-correlation potential

 $V_{pseudo}(r)$ potential mimicking the bare nuclear Coulomb

potential and the effects of the core electrons

k point in Brillouin Zone

 $G_{nk}^0(\omega)$ non-interacting Green's function

 f_{nk} occupation factor

 $G_{nk}(\omega)$ exact Green's function

 $\Sigma_{nk}(\omega)$ GW self-energy

 χ response function

 $\Omega_{GG'}$ plasmon frequencies

 E_{nk}^{QP} quasiparticle energy

 Z_{nk} renormalization factor

 E_{ck} quasiparticle energies of conduction band

 E_{vk} quasiparticle energies of valence band

 A_{vck}^{S} exciton amplitude

 Ω^s exciton eigenvalue

K^{eh} electron-hole interaction kernal